

| L Numb r | Hits | S arch Text | DB | Time stamp |
|-------------|--------|---|---|---------------------|
| - | 33465 | F urier near transf rm | USPAT; US-PGPUB; DERWENT | 2003/06/25 10:24 |
| - | 875 | ((F urier near transf rm) and phot resist | USPAT; US-PGPUB; DERWENT | 2003/06/25 10:24 |
| - | 45 | ((Fourier near transform) and photoresist) and (beam near shape) | USPAT; US-PGPUB; DERWENT | 2003/06/25 10:45 |
| - | 1068 | "Hadamard transform" | USPAT; US-PGPUB; DERWENT | 2003/06/25 10:46 |
| - | 8 | "Hadamard transform" and photoresist | USPAT; US-PGPUB; DERWENT | 2003/06/25 10:46 |
| - | 846 | (430/312).CCLS. | USPAT; US-PGPUB; DERWENT | 2003/06/25 11:19 |
| - | 60 | ((430/312).CCLS.) and (multipl\$3 with ((resist or photoresist) same layer)) | USPAT; US-PGPUB; DERWENT | 2003/06/25 15:24 |
| - | 85 | Bae-Sang\$.in. | USPAT; US-PGPUB; DERWENT | 2003/06/25 11:50 |
| - | 36 | Bae-Sang\$.in. and (resist or photoresist) | USPAT; US-PGPUB; DERWENT | 2003/06/25 15:23 |
| - | 1841 | (430/311).CCLS. | USPAT; US-PGPUB; DERWENT | 2003/06/25 15:23 |
| - | 62 | ((430/311).CCLS.) and (multipl\$3 with ((resist or photoresist) same layer))) | USPAT; US-PGPUB; DERWENT | 2003/06/25 16:11 |
| - | 51 | Jain-Kanti\$.in. | USPAT; US-PGPUB; DERWENT | 2003/06/25 16:18 |
| - | 251628 | (laser and (beam or spot)) | USPAT; US-PGPUB; DERWENT | 2003/06/25 17:42 |
| - | 20 | (laser and ((beam or spot) with (shape and size))) and (multipl\$3 with ((resist or photoresist) same layer)) | USPAT; US-PGPUB; DERWENT | 2003/06/25 17:46 |
| - | 95 | (laser and ((beam or spot) with (shape and size))) and ((resist or photoresist) same (multi\$layer or (multipl\$3 near layer))) | USPAT; US-PGPUB; DERWENT | 2003/06/25 17:49 |
| - | 9 | (resist or photoresist) with ((surface near treat\$4) with ozone) | USPAT; US-PGPUB; DERWENT | 2003/06/26 16:26 |
| - | 1388 | (430/322).CCLS. | USPAT; US-PGPUB; EP ; JPO; DERWENT | 2003/06/30 09:59 |

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| - | 51 | ((430/322).CCLS.) and (MEMS r micr structure) | USPAT; US-PGPUB; EPO; JPO; DERWENT | 2003/06/30 10:08 |
| - | 12 | ((430/322).CCLS.) and (SL r SLA or stere \$lith graph\$5) | USPAT; US-PGPUB; EPO; JPO; DERWENT | 2003/06/30 10:14 |
| - | 212 | ((430/322).CCLS.) and (resist or photoresist) and (multi\$layer or (multipl\$ with layer)) | USPAT; US-PGPUB; EPO; JPO; DERWENT | 2003/06/30 10:17 |